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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of: **HAEMATSU, Hitoshi**

Group Art Unit: **2822**

Serial No.: **10/659,337**

Examiner: **Pamela E. PERKINS**

Filed: **September 11, 2003**

P.T.O. Confirmation No.: 7094

For. **SEMICONDUCTOR DEVICE AND MANUFACTURING METHOD THEREOF**

INFORMATION DISCLOSURE STATEMENT AND
STATEMENT PURSUANT TO 37 CFR 1.97(c)

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

December 28, 2004

Sir:

The attention of the Patent and Trademark Office is hereby directed to the documents listed on the attached Form PTO-1449. One copy of each of these documents is attached.

This Information Disclosure Statement is being submitted after issuance of a first official action on the merits and expiration of the three month period following the filing date or the entry in the national stage for the above-captioned application, but prior to issuance of either a final official action, a Notice of Allowance, or an action that otherwise closes prosecution in the application.

The undersigned hereby certifies

XX that each item of information contained in this statement was first cited in any communication from a foreign patent office in a counterpart foreign application not more than three months prior to the filing of this statement.

The above information is presented so that the Patent and Trademark Office may, in the first instance, determine any materiality thereof to the claimed invention. It is respectfully requested that

the information be expressly considered during the prosecution of this application, and that the references cited in the attached Form PTO-1449 be made of record therein and appear on the first page of any patent to issue therefrom.

The Commissioner is authorized to charge Deposit Account No. 01-2340 for any fee which is deemed by the Patent and Trademark Office to be required to effect consideration of this statement.

Respectfully submitted,

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Atty. Docket No. **020721A**

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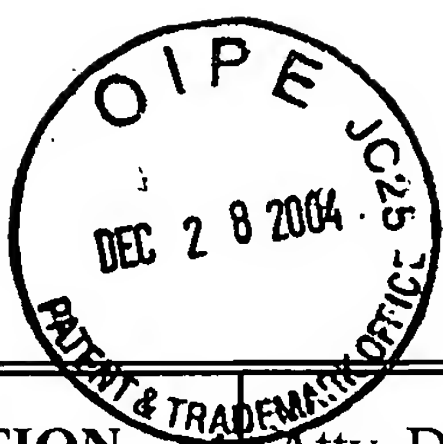
PATENT TRADEMARK OFFICE

Enclosures: PTO 1449

5 References

Copy of Japanese Patent Office Action for corresponding Japanese Patent Application

No. 2001-165701 dated September 28, 2004



INFORMATION DISCLOSURE CITATION PTO-1449	Atty. Docket No. 020721A	Serial No. 10/659,337
	Applicant(s): HAEMATSU, Hitoshi	
	Filing Date: September 11, 2003	Group Art Unit: 2822

U.S. PATENT DOCUMENTS

Examiner Initial		Document No.	Name	Date	Class	Subclass	Filing Date (If appropriate)
_____	AA						
_____	AB						
_____	AC						
_____	AD						
_____	AE						

FOREIGN PATENT DOCUMENTS

		Document No.	Date	Country	Translation (Yes or No)
_____	AF	4-139729	05/13/1992	Japan	Abstract
_____	AG	61-19154	01/28/1986	Japan	Abstract
_____	AH	8-107120	04/23/1996	Japan	Abstract
_____	AI	11-26633	01/29/1999	Japan	Abstract
_____	AJ	8-97214	04/12/1996	Japan	Abstract

OTHER DOCUMENTS

_____	AK	
_____	AL	

Examiner	Date Considered
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